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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
09/652,495	08/31/2000	Salman Akram	3847US (98-541)	3659
7590	12/28/2005		EXAMINER PAREKH, NITIN	
Brick G Power Trask Britt P O Box 2550 Salt Lake City, UT 84110			ART UNIT 2811	PAPER NUMBER

DATE MAILED: 12/28/2005

Please find below and/or attached an Office communication concerning this application or proceeding.

Office Action Summary	Application No.	Applicant(s)	
	09/652,495	AKRAM, SALMAN	
	Examiner	Art Unit	
	Nitin Parekh	2811	

-- The MAILING DATE of this communication appears on the cover sheet with the correspondence address --
Period for Reply

A SHORTENED STATUTORY PERIOD FOR REPLY IS SET TO EXPIRE 3 MONTH(S) OR THIRTY (30) DAYS, WHICHEVER IS LONGER, FROM THE MAILING DATE OF THIS COMMUNICATION.

- Extensions of time may be available under the provisions of 37 CFR 1.136(a). In no event, however, may a reply be timely filed after SIX (6) MONTHS from the mailing date of this communication.
- If NO period for reply is specified above, the maximum statutory period will apply and will expire SIX (6) MONTHS from the mailing date of this communication.
- Failure to reply within the set or extended period for reply will, by statute, cause the application to become ABANDONED (35 U.S.C. § 133). Any reply received by the Office later than three months after the mailing date of this communication, even if timely filed, may reduce any earned patent term adjustment. See 37 CFR 1.704(b).

Status

- 1) ☒ Responsive to communication(s) filed on 24 October 2005.
- 2a) ☐ This action is **FINAL**. 2b) ☒ This action is non-final.
- 3) ☐ Since this application is in condition for allowance except for formal matters, prosecution as to the merits is closed in accordance with the practice under *Ex parte Quayle*, 1935 C.D. 11, 453 O.G. 213.

Disposition of Claims

- 4) ☒ Claim(s) 1-3,5-41 and 43-55 is/are pending in the application.
- 4a) Of the above claim(s) _____ is/are withdrawn from consideration.
- 5) ☐ Claim(s) _____ is/are allowed.
- 6) ☒ Claim(s) 1-3,5-41 and 43-55 is/are rejected.
- 7) ☐ Claim(s) _____ is/are objected to.
- 8) ☐ Claim(s) _____ are subject to restriction and/or election requirement.

Application Papers

- 9) ☐ The specification is objected to by the Examiner.
- 10) ☒ The drawing(s) filed on 08-31-2000 is/are: a) ☒ accepted or b) ☐ objected to by the Examiner.
 Applicant may not request that any objection to the drawing(s) be held in abeyance. See 37 CFR 1.85(a).
 Replacement drawing sheet(s) including the correction is required if the drawing(s) is objected to. See 37 CFR 1.121(d).
- 11) ☐ The oath or declaration is objected to by the Examiner. Note the attached Office Action or form PTO-152.

Priority under 35 U.S.C. § 119

- 12) ☐ Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f).
- a) ☐ All b) ☐ Some * c) ☐ None of:
1. ☐ Certified copies of the priority documents have been received.
2. ☐ Certified copies of the priority documents have been received in Application No. _____.
3. ☐ Copies of the certified copies of the priority documents have been received in this National Stage application from the International Bureau (PCT Rule 17.2(a)).
- * See the attached detailed Office action for a list of the certified copies not received.

Attachment(s)

- | | |
|---|---|
| 1) <input checked="" type="checkbox"/> Notice of References Cited (PTO-892) | 4) <input type="checkbox"/> Interview Summary (PTO-413) |
| 2) <input type="checkbox"/> Notice of Draftsperson's Patent Drawing Review (PTO-948) | Paper No(s)/Mail Date. _____ |
| 3) <input type="checkbox"/> Information Disclosure Statement(s) (PTO-1449 or PTO/SB/08) | 5) <input type="checkbox"/> Notice of Informal Patent Application (PTO-152) |
| Paper No(s)/Mail Date _____ | 6) <input type="checkbox"/> Other: _____ |

DETAILED ACTION

1. In view of the appeal brief filed on 10-24-05, PROSECUTION IS HEREBY REOPENED.

A. A new ground of rejection for the claims 1-3, 5-41 and 43-55 is set forth below.

2. To avoid abandonment of the application, appellant must exercise one of the following two options:

(1) file a reply under 37 CFR 1.111 (if this Office action is non-final) or a reply under 37 CFR 1.113 (if this Office action is final); or,

(2) request reinstatement of the appeal.

If reinstatement of the appeal is requested, such request must be accompanied by a supplemental appeal brief, but no new amendments, affidavits (37 CFR 1.130, 1.131 or 1.132) or other evidence are permitted. See 37 CFR 1.193(b)(2).

3. Applicant is reminded that if an appeal brief is filed, the appeal brief should include section ix (Evidence appendix) and section x (Related proceedings appendix) as indicated in paragraphs (c), 1(ix) and 1(x) under 37 CFR 41.37.

Claim Rejections - 35 USC § 112

4. The following is a quotation of the second paragraph of 35 U.S.C. 112:

The specification shall conclude with one or more claims particularly pointing out and distinctly claiming the subject matter, which the applicant regards as his invention.

5. Claim 11 recites the limitation "the another surface" in line 1. There is insufficient antecedent basis for this limitation in the claim.

Claim Rejections - 35 USC § 102

6. The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless –

(b) the invention was patented or described in a printed publication in this or a foreign country or in public use or on sale in this country, more than one year prior to the date of application for patent in the United States.

7. Claims 1, 3, 5-9, 19 21, 22, 30-35, 43, 44 and 50-52, insofar as being in compliance with 35 U.S.C. 112, are rejected under 35 U.S.C. 102(b) as being anticipated by Lin (US Pat. 5258648).

Regarding claim 1, 3, 5-9 and 19, Lin discloses a chip scale package (CSP)/flip chip composite package/flip chip carrier (FCC see 10 in Fig. 1-5) comprising:

- a semiconductor device/silicon chip (12 in Fig. 1) including an active surface having bond pads (14 in Fig. 1), the device being invertedly disposed on a first/top surface of a substrate/interposer (22 in Fig. 1-5)
- the substrate comprising a semiconductor material such as silicon (Col. 6, lines 30-40) having substantially the same coefficient of thermal expansion (CTE) as that of the device/chip, the device/chip and the substrate (12 and 22 respectively

in Fig. 1 and 3) having respective first and second thicknesses being substantially the same

- the substrate having electrically conductive traces (26 in Fig. 1) on a first surface, being disposed adjacent the active surface of the device and the substrate including a plurality of electrically conductive/filled vias on respective contact areas extending there-through (24 in Fig. 4; Col. 4, lines 52-65), the electrically conductive filled vias/material having one end being in electrical communication with/bonded to the conductive traces/contact areas and corresponding bond pads (Fig. 1-4) of the device, and
- electrically conductive solder balls/bumps (32 in Fig. 4; Col. 5, line 23) protruding from a second surface, the second surface being opposite to the first surface and the bumps being in electrical communication with respective electrically conductive vias

(Fig. 1-6; Col. 3, line 55- Col. 8, line 65).

Lin further discloses the substrate having conductive traces in communication of the vias, the traces being carried on/routed on the opposite surface/bottom surface extending in lateral directions from an end/second end of the conductive via of the plurality of the conductive vias (see traces 43/44 with respect to the solder balls/vias in Fig. 6; Col. 8, line 55-60; Col. 7, line 35-55) to provide the desired routing for the vias and power/ground connections for the terminals/solder balls (Col. 6-8).

Regarding claims 21, 22 and 32-35, Lin discloses the entire claimed structure as applied to claim 1 above.

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Regarding claims 43, 44 and 50-52, Lin discloses the entire claimed structure as applied to claim 1 above.

Claim Rejections - 35 USC § 103

8. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

(a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be

patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negated by the manner in which the invention was made.

9. Claims 2, 11-14 and 20, insofar as being in compliance with 35 U.S.C. 112, are rejected under 35 U.S.C. 103(a) as being unpatentable over in view of Lin (US Pat. 5258648) in view of Gnadinger (US Pat. 5229647).

Regarding claim 2, Lin teaches substantially the entire claimed structure as applied to claim 1 above, except an electrically conductive bump protruding from the substrate opposite the semiconductor device, being in communication with the at least one electrically conductive via, and located at an opposite end of the at least one conductive trace from the at least one electrically conductive via.

Gnadinger teaches a multichip scale package comprising silicon substrate having a conventional via/bump configuration including electrically conductive/filled vias and protruding bump (see 21 and 20 respectively in Fig. 4) from a surface/bottom of the substrate wherein the electrically conductive vias are plated with conventional metal plating/trace (see 28 in Fig. 4) such that the bump is in electrical communication with the electrically conductive via (Col. 3, line 35- Col. 4, line 35). Furthermore, the protruded bump is located at an opposite end/bottom of the electrically conductive metal plating/trace.

It would have been obvious to a person of ordinary skill in the art at the time invention was made to incorporate electrically conductive bump protruding from the substrate opposite the semiconductor device, being in communication with the at least one electrically conductive via, and located at an opposite end of the at least one conductive trace from the at least one electrically conductive as taught by Gnadinger so that the via interconnect reliability can be improved in Lin's package.

Regarding claims 11-14, Lin teaches substantially the entire claimed structure as applied to claim 1 above, but fail to specify the second surface of the substrate being partially coated or substantially extended over with an insulating material.

Gnadinger teaches the multichip package where silicon/wafer substrates having aligned vias and bumps (21 and 28 respectively in Fig. 4) are formed with an insulating layer (24 in Fig. 4) such as a silicon oxide, the insulating layer extending substantially over the substrate surface opposite to that having device pads and the vias being exposed through the insulating material (Col. 4, line 28).

It would have been obvious to a person of ordinary skill in the art at the time invention was made to incorporate the second surface of the substrate being partially coated or substantially extending over with an insulating material as taught by Gnadinger so that the passivation and surface protection for the substrate can be improved in Lin's package.

Regarding claim 20, Lin teaches substantially the entire claimed structure as applied to claim 1 above, except forming a diffusion region comprising a bond pad and via material.

Gnadinger teaches the multichip package where a diffusion region is formed comprising via, bond pad and their material, the region securing the device to the substrate (23 in Fig. 4; Col. 4, line 23).

It would have been obvious to one of ordinary skill in the art at the time invention was made incorporate a diffusion region between the bond pad and via, the region securing the device to the substrate as taught by Gnadinger so that the metallurgical bonding and electrical performance of the device can be improved in Lin's package.

Regarding claims 23-25, Lin and Gnadinger teach substantially the entire claimed structure as applied to claims 1, 21 and 20 above.

Regarding claims 30 and 31, Lin and Gnadinger teach substantially the entire claimed structure as applied to claims 1, 21 and 2 above.

Regarding claims 37-41, Lin and Gnadinger teach substantially the entire claimed structure as applied to claims 1, 21 and 11-14 above.

Regarding claims 45-49, Lin and Gnadinger teach substantially the entire claimed structure as applied to claims 1, 43 and 11-14 above.

10. Claim 10, 15, 18, 26, 27 and 36, insofar as being in compliance with 35 U.S.C. 112, are rejected under 35 U.S.C. 103(a) as being unpatentable over Lin (US Pat. 5258648) in view of Kim et al. (US Pat. 6004867)

Regarding claim 10, Lin teaches substantially the entire claimed structure as applied to claim 1 above, except a first thickness of the semiconductor device being greater than that of the semiconductor substrate.

Kim et al. teach a CSP/FCC wherein a first thickness of the semiconductor device/chip (110 in Fig. 2) is greater than that of the semiconductor substrate (120 in Fig. 2).

It would have been obvious to a person of ordinary skill in the art at the time invention was made to incorporate first thickness of the semiconductor device being greater than that of the semiconductor substrate as taught by Kim et al. so that manufacturing yield and processing/cycle time can be improved in Lin et al's package.

Regarding claims 15 and 18, Lin teaches substantially the entire claimed structure as applied to claim 1 above, except an intermediate layer being disposed between the device and the substrate adhering the device and the substrate and the conductive vias, conductive traces and corresponding bond pads being in communication through the intermediate layer.

Kim et al. teach the CSP/FCC comprising an intermediate/passivation layer (114 in Fig. 2; Col. 3, line-5) being disposed between the device and the substrate adhering the device and the substrate.

It would have been obvious to a person of ordinary skill in the art at the time invention was made to incorporate intermediate layer being disposed between the device and the substrate adhering the device and the substrate and the conductive vias, conductive traces and corresponding bond pads being in communication through the intermediate layer as taught by Kim et al. so that the surface protection can be improved in Lin's package.

Regarding claims 26 and 27, Lin and Kim et al. teach substantially the entire claimed structure as applied to claims 1, 21, 15 and 18 above.

Regarding claim 36, Lin and Kim et al. teach substantially the entire claimed structure as applied to claims 1, 21 and 10 above.

11. Claims 16, 17, 28, 29 are rejected under 35 U.S.C. 103(a) as being unpatentable over Lin (US Pat. 5258648) and Kim et al. (US Pat. 6004867) and as applied to claims 1, above, and further in view of Higgins, III (US Pat. 6294405).

Regarding claims 16 and 17, Kim et al. and Lin teach substantially the entire claimed structure as applied to claim 1 above, except the intermediate layer comprising an adhesive material or polyimide.

Higgins, III teaches using an intermediate passivation/adhesion layer (18 in Fig. 1) adjacent a such as polyimide, silicon oxide, etc. (Col. 2, line 65) to provide a protection and bonding/adhesion for the device in a CSP.

It would have been obvious to a person of ordinary skill in the art at the time invention was made to incorporate an intermediate layer comprising an adhesive material as taught by Higgins, III so that the passivation and surface protection can be improved in Lin and Kim et al's package.

Regarding claims 28 and 29, Lin, Kim et al. and Higgins, III teach substantially the entire claimed structure as applied to claims 1, 21 and 16 and 17 above.

12. Claims 53-55 are rejected under 35 U.S.C. 103(a) as being unpatentable over in view of Lin (US Pat. 5258648) in view of Tokuda et al. (US Pat. 5870289).

Regarding claims 53-55, Lin teaches substantially the entire claimed structure as applied to claims 1 and 43 above, except an adhesive layer disposed adjacent the first surface of the substrate.

Tokuda et al. teach a chip/substrate structure having through-holes/vias wherein a conventional adhesive layer/polyimide (see 30 in Fig. 1) is disposed adjacent/on a first/top surface of a wiring substrate (20 in Fig. 1) such that the through-holes/vias extend through the adhesive layer to provide the desired electrical connection (see 40 in Fig. 1; Col. 10, line 30- Col. 11, line 10).

It would have been obvious to a person of ordinary skill in the art at the time invention was made to incorporate the polyimide/adhesive layer being disposed

adjacent the first surface of the substrate wherein one end of at least one end of the via extends through the adhesive layer as taught by Tokuda et al. so that the passivation/surface protection for the substrate can be improved in Lin and Kim et al's package.

Response to Arguments

13. Applicant's arguments with respect to claims 1-3, 5-41 and 43-55 have been considered but are moot in view of the new ground(s) of rejection.

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Nitin Parekh whose telephone number is 571-272-1663. The examiner can normally be reached on 09:00AM-05:30PM.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Eddie Lee can be reached on 571-272-1732. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9318.

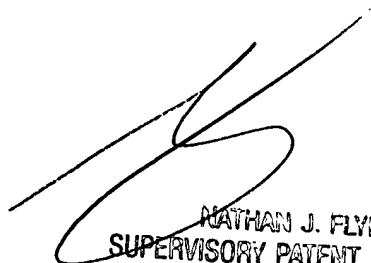
Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAN or Public PAG. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see <http://pair-direct.uspto.gov>. Should you have

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questions on access to the Private PAG system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free). Any inquiry of a general nature or relating to the status of this application or proceeding should be directed to the receptionist whose telephone number is 703-308-0956.

NP

12-23-05



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